

L Number	Hits	Search Text	DB	Time stamp
1	27940	((amorphous non/crystal\$5) near5 silicon)	USPAT; US-PGPUB	2003/07/05 12:14
2	9972	((amorphous non/crystal\$5) near5 silicon)) and oxygen	USPAT; US-PGPUB	2003/07/05 12:08
3	11549	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")	USPAT; US-PGPUB	2003/07/05 12:14
4	10797	((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")	USPAT; US-PGPUB	2003/07/05 12:15
5	11897	((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")	USPAT; US-PGPUB	2003/07/05 12:15
6	17464	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2"))	USPAT; US-PGPUB	2003/07/05 12:09
7	14502	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")) and (anneal\$3 heat\$3 cryatalliz\$3)	USPAT; US-PGPUB	2003/07/05 12:16
8	14639	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")) and (anneal\$3 heat\$3 crystalliz\$3)	USPAT; US-PGPUB	2003/07/05 12:11
9	2160	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")) and (anneal\$3 heat\$3 crystalliz\$3)) and ((anneal\$3 heat\$3 crystalliz\$3) near100 silicon near100 (environment gas atmosphere))	USPAT; US-PGPUB	2003/07/05 12:18
10	5425	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")) and (anneal\$3 heat\$3 crystalliz\$3)) and ((anneal\$3 heat\$3 crystalliz\$3) same silicon same (environment gas atmosphere))	USPAT; US-PGPUB	2003/07/05 12:18
11	5425	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")) and (anneal\$3 heat\$3 crystalliz\$3)) and ((anneal\$3 heat\$3 crystalliz\$3) near100 silicon near100 (environment gas atmosphere))) (((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")) and (anneal\$3 heat\$3 crystalliz\$3)) and ((anneal\$3 heat\$3 crystalliz\$3) same silicon same (environment gas atmosphere)))	USPAT; US-PGPUB	2003/07/05 12:12

14	1698	(((((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) ((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) ((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")) and (anneal\$3 heat\$3 crystalliz\$3)) and ((anneal\$3 heat\$3 crystalliz\$3) near100 silicon near100 (environment gas atmosphere))) (((((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")) and (anneal\$3 heat\$3 crystalliz\$3)) and ((anneal\$3 heat\$3 crystalliz\$3) same silicon same (environment gas atmosphere))) and ((TFT (thin near3 film near3 transistor)))	USPAT; US-PGPUB	2003/07/05 12:19
15	22106	((amorphous non/crystal\$5) near5 silicon)	EPO; JPO; DERWENT; IBM_TDB	2003/07/05 12:14
16	1507	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")	EPO; JPO; DERWENT; IBM_TDB	2003/07/05 12:15
17	555	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) and (nitrogen N2 "N.sub.2")	EPO; JPO; DERWENT; IBM_TDB	2003/07/05 12:15
18	1449	((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")	EPO; JPO; DERWENT; IBM_TDB	2003/07/05 12:15
19	2627	((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")	EPO; JPO; DERWENT; IBM_TDB	2003/07/05 12:16
20	4478	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) ((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) and (nitrogen N2 "N.sub.2")) ((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) ((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2"))	EPO; JPO; DERWENT; IBM_TDB	2003/07/05 12:16
22	1265	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) ((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) and (nitrogen N2 "N.sub.2")) ((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) ((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")) and (anneal\$3 heat\$3 cryatalliz\$3)	EPO; JPO; DERWENT; IBM_TDB	2003/07/05 12:16
24	600	((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) ((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) and (nitrogen N2 "N.sub.2")) ((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) ((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")) and (anneal\$3 heat\$3 cryatalliz\$3)) and ((anneal\$3 heat\$3 crystalliz\$3) same silicon same (environment gas atmosphere))	EPO; JPO; DERWENT; IBM_TDB	2003/07/05 12:18

25	37	((((((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) ((((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2")) and (nitrogen N2 "N.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) (((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")))) and (anneal\$3 heat\$3 cryatalliz\$3)) and ((anneal\$3 heat\$3 crystalliz\$3) same silicon same (environment gas atmosphere))) and ((TFT (thin near3 film near3 transitor)))	EPO; JPO; DERWENT; IBM_TDB	2003/07/05 12:19
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